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- Silicon nitride sintered bodies and a method for their production.
- (5) Silicon nitride sintered bodies which contain no more than 15% by weight metallic non-oxide compounds as silicon nitride high temperature grain growth inhibitors and total amount of 4–25% of MgO and Al₂O₃ as densifying aids in MgO/Al₂O₃ weight ratio being 19 to 2.

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SILICON NITRIDE SINTERED BODIES

AND A METHOD FOR THEIR PRODUCTION

This invention relates to silicon nitride sintered bodies resulting from the sintering of a raw material or powder composition based on Si₃N₄ enabling sintered objects to be prepared by pressureless sintering. The invention also relates to the method for the manufacture of articles of silicon nitride by pressureless sintering of the above-mentioned raw material powder.

Silicon nitride is known to be a very hard material which is suitable for manufacturing parts having high mechanical strength at high temperature (shafts, gas turbine blades, parts in contact with 10 liquid metals, block bearings, ball bearings, sealing segments etc..), provided its degree of porosity is low. In this respect, the higher the degree of porosity of this material, the less it resists breakage forces and hot oxidation corrosion. A Si_3N_4 of very low porosity can be manufactured which is suitable for the aforesaid applica-15 tions by hot uniaxial pressing. By this method, compact $\mathrm{Si}_{3}\mathrm{N}_{A}$ is obtained in the form of blocks, which are very costly to convert into complex mechanical parts because of the extreme hardness of the material, the special tools (diamond clad) required for their machining, and the slowness of this work. Thus, an active attempt has been 20 made during recent years to directly form parts by molding or stamping powder compositions based on Si_3N_A followed by sintering at high temperature under an inert atmosphere. In doing this, the following three basic factors have proved important: the addition of densification aids, the use of powders of fine particle size (of the order 25 of 1 to a few um) and, during sintering the use of a relatively high nitrogen pressure of the order of 2 to 50 atmospheres. By means of these improvements, densification levels of the order of 95 to 97% of the theoretical density are now achieved $(3.03 - 3.097 \text{ g/cm}^3)$.

The most important publications in this field include, for exam30 ple: I. ODA, M. KANENO and N. YAMAMOTO, "Pressureless sintered silicon nitride" Nitrogen Ceramics, ed. F.L. RILEY, Nordhoff (Leyden)
1977, 359-365; M. MITOMO et al., Yogyo Kyokai Shi 1976, 84(8), 356

- 360 (Japan); Japan J. Mater, Sci 1976, 11(6), 1103-7; Japanese Ko-kai patent specification 77 47,015; M. MITOMO et al., Yogyo Kyokai Shi 1977, 85(8), 408-12; G.R. TERWILLIGER & F. F. LANGE, Journal of Materials Science 10 (1975) 1169-1174; US Patent No. 3,992,497 and "Sintering of silicon nitride" by D.J. ROWCLIFFE & P.J. JORGENSEN, Stanford Research Institute, Menlo Park, Calif.

The most common densification aids include MgO (5%); $Al_2O_3 + Y_2O_3(10-50\%)$; BeO(1.25%) + MgO(3.75%); BeO(1.25%) + MgO(3.75%) + CeO₂(5%), etc..

Despite the excellent results on maximal densities and flexural strength (in the order of 400 MPa at $1400\,^{\circ}$ C) obtained by applying the recently developed techniques of the prior-art, some difficulties still remain in connection with the structural stability of the ceramic material under high temperature applications (for instance high temperature turbine blades). These difficulties mainly affect density changes, λ to β phase conversion, further grain growth and flexural strength losses at high temperature.

Attemps have been made to remedy these drawbacks by the addition to the $\mathrm{Si}_3\mathrm{N}_4$ compositions of non-oxide metal compounds such as 20 SiC, TiC, WC, TiN and TiB $_2$ with the expectation that such material can act as grain growth inhibitors and prevent or minimize the oxidation of $\mathrm{Si}_3\mathrm{N}_4$ to SiO_2 under heating. Thus, for instance, Japanese Kokai No. 81-32377 (79-104 927) discloses a sintered silicon nitride material for cutting tools having the following composition: 5 to 40 weight % of one or more of carbide, nitride or carbo-nitride of titanium; 10 weight % or less of one or more of aluminum nitride, aluminum oxide, magnesium oxide, silicon oxide, and oxides of Fe, Co, Ni, and rare earth metals.

Japanese Kokai No. 82-123865 (81-16589) discloses a method for making a dense silicon nitride sintered body containing TiN and/or AlN and oxides such as Y_2O_3 , Al_2O_3 , MgO, ZrO_2 , TiO_2 , BeO, La_2O_3 and CeO_2 .

Japanese Kokai No. 82-129875 (81-16589) discloses a tool for working copper and copper alloys made of a ceramic containing Si₃N₄, ³⁵ 1 to 40 wt% of one or more of AlN, Al₂O₃, Y₂O₃, MgO, CaO, ZnO₂, TiO₂, HfO₂, SiC, CeO, BeO, TiN, Mg₂N₃, Al, etc.., and also a tool containing Si₃N₄ and 20 wt% or less of WC and/or Mo₃C relative to the Si₃N₄.

Japanese Kokai No. 82-188467 (81-73814) discloses a silicon nitride based sintering composition comprising 70 to 97 wt% of silicon nitride, 1 to 20 wt% of titanium nitride, and 2 to 20 wt% of an oxide of rare earth metals.

Japanese Kokai No. 82-205376 (81-89330) discloses a dense sintering composition for a cutting tool, comprising Si₃N₄ and Al₂O₃ in a ratio of 50/50 to 90/10, Si₃N₄ containing 1 to 15 wt% of one or more of Y₂O₃, MgO, ZrO₃, and stabilized ZrO₂; and Al₂O₃ containing 10 to 50 wt% of two or more of TiC, TiN and TiCN. The reference also discloses a process for producing a sintering composition for making cutting tools, characterized by (a) mixing (i) a powder of Si₃N₄ consisting of 90 wt% or more of Al₂O₃, MgO, ZrO₂, and containing 1 to 15 wt% of one or more of Y₂O₃, MgO, ZrO₂, and stabilized ZrO₂, and (ii) a powder of Al₂O₃ containing 10 to 50 wt% of two or more of TiC, TiN, and TiCN, Si₃N₄ and Al₂O₃ being in the ratio of 50/50 to 90/10, and (b) sintering under pressure at a high temperature to the density of 97 to 100% of the theoretical density.

Japanese Kokai 82-207136 (81-92568) discloses a process for producing a sintering composition for a cutting tool involving (a) mixing (i) 20 to 40 wt% of a Ti-containing powder containing TiO₂ and/or
Ti, and TiC in the ratio of 5:95 to 20:80, (ii) 10 to 50 wt% of an Al₂O₃-based powder comprising 60 to 80 wt% of Al₂O₃, and (iii) 50 to 90 wt% of an Si₃N₄-based powder containing 1 to 15 wt% of one or more of Y₂O₃, MgO, ZrO₂, and stabilized ZrO₂, and (b) sintering under pressure at a high temperature to the density of 97 to 100% of the theoretical density. In a modification of the above, 50% or less of TiC is replaced by TiN, WC, TaC, Mo₂C, or NbC.

Japanese Kokai 83-20782 (81-118239) discloses a silicon nitride sintering powder containing (a) 95 to 70 wt% of silicon nitride containing more than 80 wt% of -silicon nitride and having a content of oxygen of 5 wt% or less, (b) 2 to 20 wt% of at least one of oxide powder such as Y₂O₃, Sc₂O₃, La₂O₃, Ce₂O₃, Al₂O₃, Cr₂O₃, MgO, and (c) 0.5 to 20 wt% of one or more powders selected from oxides, nitrides, carbides and borides of elements in the groups 4B, 5B, 6B of the Periodic Table, B₄C, and Al₄C. The reference further discloses a silicon nitride sintering product according to claim 1 having an electrical conductivity of more than 10-3Ω-lcm-1 and being machinable by elec-

troerosion.

Japanese Kokai 83-60677 (81-155453) discloses a process for producing a hard sintered silicon nitride article by mixing (i) 95 to 57 wt% of metal silicon powder having a maximum particle size of 25/um or less, (ii) 1 to 15 wt% based on TiN of a titanium ingredient powder capable of becoming TiN during the sintering reaction or a TiN powder having a maximum particle size of 20/um or less, and (iii) 2 to 28 wt% of one or more compounds selected from AlN, Al₂O₃, SiO₂, and oxides of rare earth metals; shaping the mixture, reaction sintering in an nonoxidizing atmosphere of nitrogen or a gas mixture containing nitrogen, and then sintering again at 1600°C to 2000°C under the same atmosphere as above.

Japanese Kokai 83-74572 (82-134446) discloses a tool for working copper and copper alloys, comprising (i) 60 wt% or more of Si₃N₄, 15 (ii) 1 to 25 wt% of one or more of oxides, carbides, borides, nitrides or silicides of the elements of the IIIB group in the Periodic Table, and (iii) 1 to 25 wt% of one of Al, Al₂O₃ and AlN; and having pores of 5% or less.

Japanese Kokai 83-95644 (81-190186) discloses a high strength 20 complex sintering composition comprising (i) silicon nitride, (ii) 20 to 75 wt% of one or more of metal nitrides and carbides such as titanium nitride, zirconium nitride, zirconium carbide, vanadium carbide, and (iii) 10 wt% or less of one or more of aluminum oxide, magnesium oxide and oxides of rare earth metals.

Japanese Kokai 83-161975 (82-41916) discloses silicon nitride based workpieces containing TiN, aluminum nitride together with Al₂O₃, Y₂O₃ and/or SiO₂ and/or rare earths. For instance, silicon nitride in an amount 70 - 97.5 wt%, TiN powder in an amount of 0.5 - 15 wt% and a mixture of at least one of AlN, Al₂O₃ and SiO₂ and one or more of Y₂O₃ and oxides of rare earths in an amount of 2 - 20 wt% are mixed and moulded and burnt in a non-oxidative gaseous atmosphere (N₂). TiN makes the grains of the sintered body very small and heightens the strength of the body at high temperature. The structure of the sintered body is fibriform and has high strength and tenacity at high temperature when used for parts of gas turbines.

The present inventors have now found that the above advantages can still be markedly transcended with the sintered bodies defined

in claim 1 containing $\mathrm{Si}_3\mathrm{N}_4$ in conjunction with SiC, TiC, WC, TiN and TiB_2 , the quantity of such metallic compounds being defined in claim 1 and, as densifying additives MgO and $\mathrm{Al}_2\mathrm{O}_3$ in quantities and particles size as defined also in claim 1.

Preferably, the amount of MgO in the sintered bodies defined in claim 2 is 5 to 15% by weight and the amount of Al₂O₃ is 0.5 to 6% by weight. Other preferably used ratios of ingredients are defined in claim 2.

After milling the particle size of the various ingredients is 10 preferably in the 0.01 to 0.5 um range.

The type of $\mathrm{Si}_3\mathrm{N}_4$ used for making present sintered articles is preferably the $^{\prime}$ -type. During sintering the $^{\prime}$ -form converts itself to the $^{\beta}$ -form; the extent of formation is an indication of the effectiveness of the sintering additives including the metallic non-oxi-15 de compounds.

For making a sintered object the various ingredients selected in powder form are mixed and, if particle size requires it, are ground in a ball-mill until the desired particle size is attained. Grinding solvents can be water or organic solvents such as various fractions of petroleum (for instance light petroleum) and/or lower alcohols (for instance tert-butanol). Milling balls are preferably Si₃N₄ balls as no further material other than the basic silicon nitride from the balls is introduced during milling. However when desired, other milling materials such as alumina balls and mill can also be used.

Then when the granulation of the particles is in the desired state, the following stages are preferably performed:

- (a) the powder is compacted in the cold state into the form of the desired object,
- 30 (b) this molded object is subjected in its cold state to an isostatic pressure exceeding 1 T/cm²,
 - (c) the object is heated under reduced pressure in order to degas it,
- (d) the object is heated between 1650 and 1830°C. under an es-35 sentially nitrogen atmosphere, this latter operation giving rise to the required sintering and densification.

This method is extremely advantageous, because by taking account

of the contraction during densification (of the order of 40 to 60% by volume) the object can be formed of approximately the required proportions, for example by moulding or stamping, so enabling further machining to be reduced to a strict minimum. It is also possible to 5 grind the part before sintering (green machining) or after pre-sintering below 1300°C.

Preferably, after stage (a), which is carried out by the usual known means, stage (b) is carried out at 2 T/cm². To attain this, the molded object can for example be wrapped in a flexible plastic sheet and the whole subjected to a hydrostatic pressure by means of a liquid such as oil in a suitable press. Alternatively, the object can be molded in a rubber mold, the mold then being pressed in a piston press, the forces due to the pressure then becoming distributed uniformly in all directions by way of the material constituting the mold. After cold pressing and removal from the mold, the preformed object (green) is obtained, constituted of agglomerated powder having a "green" density of the order of 1.4 to 1.8, this value depending on the particle size and the crystalline state (x', β' or amorphous form) of the Si₃N₄ used for the formulation of the starting composition.

Stages (c) and (d) can be carried out as follows: the green is placed in a graphite crucible provided with a tight fastener (for example of screw type), to reduce any N_2 losses by high temperature decomposition, and in order to prevent the green coming into di-25 rect contact with the crucible walls during heating, it is embedded in a powder which is inert at high temperature. The powder used can be uncompacted silicon nitride possibly containing boron nitride to prevent the Si₂N₄ of this mixture sintering at the temperature used for sintering the part, and thus to facilitate the stripping of the 30 part after cooling. For degassing purposes, it is then heated for about a half hour at around 800 to 1000°C. under a pressure lower than 10^{-1} Torr. A protecting atmosphere (for example N_2 or N_2 + 1% H₂) is then introduced, the temperature is raised rapidly to the sintering point, this temperature is maintained for the required time, 35 and finally the whole is allowed to cool. The heating time and sintering temperature are related in the sense that the time is shorter the higher the temperature. Preferably, heating is carried out for about 15 minutes around 1750°C. These conditions are given here only be way of example, but demonstrate the economical importance of the present method. If required, after sintering, the part can be annealed at a temperature (for example of the order of 1600°C.)

5 which stabilizes its microstructure and improves its mechanical properties.

The following Examples illustrate the invention.

10 Example 1

Sintering compositions were prepared by milling together for 168 hours in a Si₃N₄ ball mill, using Si₃N₄ balls of 4 mm size, the following ingredients: Si₃N₄ ((-form), SiC, MgO and Al₂O₃ in variable proportions. The initial particle size of the compounds was about 0.3 to 1 µm. The solid to milling fluid (3:1 mixture of petroleum ether and tert butanol) weight ratio was approximately 1:2. After milling, the average particle size was 0.2 µm. After separating from the milling balls and the milling fluid, the mixtures were formed into objects (plate 60 x 60 x 7 mm) by isostatic pressing under 2.5 T/cm² in a hydraulic press and the greens were degassed at 1000° then sintered (temperature rises about 110°/min) for 15 min at specified temperatures comprised between 1600 and 1850°C.

In this Example, the weight amount of SiC in the $\rm Si_3N_4$ was va- 25 ried from 0% to 17%, total content of MgO and $\rm Al_2O_3$ was varied from 3 to 32%, and MgO/Al₂O₃ ratio was varied from 1.5 to 29.

The sintered objects were cut into bars $3.0 \times 4.0 \times 40 \text{ mm}$ and subjected the four point flexural rupture test at room temperature (RT), 1200 and 1400°C in air.

The various operating parameters and the results are shown in Table I. The % of beta-form resulting from the sintering was ascertained by X-ray analysis.

The silicon nitride sintered bodies of the present invention are No. 1 to 10 in Table I, while the comparative examples are No. 35 11 to 17.

As seen from the results of Table I, the four point flexural strength at $1400\,^{\circ}\text{C}$ is not less than 380 MPa and the density is not

less than 3.12 g/cm3 for samples containing 0.5 to 15.0% of SiC in the presence of 4.0 to 25.0% of the total content of MgO and Al_2O_3 and MgO/ Al_2O_3 ratio being 2 to 19 (present invention).

Particularly in preferred embodiments of No. 5, 6, 7, 8 and 9 5 which have MgO contents from 5 to 15%, Al₂O₃ contents from 0.7 to 6% and SiC contents from 1 to 10% according to the present invention, the strength at 1400°C was excellent, i.e. not less than 470 MPa.

The examples Nos 11 to 15 which are not covered within the area of the present invention are also shown in Table I for comparative 10 purposes. In the case of No. 16 its density and strength are insufficient, because firing temperature was lower than the present invention. In the case of No. 17, firing temperature was too high, and so its density and strength are insufficient, because of Si₃N₄ volatilization.

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-								Firing					
	Sample No.	H Mix.	ing ra MgO	Mixing ratio (wt%) Si_3N_4 MgO Al_2O_3 SiC	wt%)	MgO+Al ₂ O ₅ (wt%)	MgO/Al ₂ 03 (wt ratio)	MgO+Al ₂ O ₃ MgO/Al ₂ O ₃ temperature Density (wt%) (wt ratio) (OC) (g/cm ³)	Density (g/cm ³)		<pre>\$-form flexural (%) RT </pre>	strength 1200°C	(MPa) 1400 ^O C
		94.6	4.6	€*0	0.5	4.9	15.3	1800	3.12	06	650	580	380
Present	2	78.0	19.0	1.0	2.0	20.0	19.0	1775	3.17	95	700	009	400
invention	т	65.0	23.7	1.3	10.0	25.0	18.2	1650	3.13	80	009	490	380
	4	86.0	3.5	0.5	10.0	4.0	7.0	1800	3.15	92	640	580	400
	5	89.3	5.0	0.7	5.0	5.7	7.1	1750	3.20	06	730	670	520
	9	83.5	14.0	1.5	1.0	15.5	9.3	1775	3.18	06	740	089	550
	7	73.3	15.0	1.7	10.0	16.7	8.8	1800	3.22	95	750	700	560
	8	74.3 14.7	14.7	0.9	5.0	20.7	2.5	1800	3.15	95	740	069	520
	6	84.1	7.4	3.5	5.0	10.9	2.1	1830	3.18	85	700	620	470
	10	60.0 16.7	16.7	8.3	15.0	25.0	2.0	1800	3.13	97	650	580	380
	=	92.0	7.0	1.0		8.0	7.0	1750	3.13	70	550	440	330
Comparative	12	0.96	2.9	0.1	1.0	3.0	29.0	1800	2.95	82	410	300	280
example	13	58.0	30.5	1.5	10.0	32.0	20.3	1775	3.00	92	450	310	280
	14	58.0 16.7	16.7	8.3	17.0	25.0	2.0	1775	3.07	95	450	380	270
	15	79.0 12.0	12.0	8.0	1.0	20.0	1.5	1775	3.15	95	440	360	240
	16	89.3	5.1	9.0	5.0	5.7	8.5	1600	2.65	09	240	210	200
	17	83.0	0.6	3.0	5.0	12.0	3.0	1850	2.95	100	400	320	230

TABLE I

Exemple 2

The procedure outlined in detail at Example 1 was repeated but using TiN instead of SiC.

In this example, the weight amount of TiN in the $\mathrm{Si_3N_4}$ was varied from 0 to 17%, the total content of MgO and $\mathrm{Al_2O_3}$ was varied from 2.9 to 30%, and MgO/Al₂O₃ ratio was varied from 1.5 to 28.

The various operating parameters and the results are gathered in Table II. The silicon nitride sintered bodies of the present invention are No. 21 to 30 in Table II, while the comparative examples are No. 31 to 37. As seen from the results of Table II, the four point flexural strength at 1400°C in air is not less than 380 MPa and the density is not less than 3.11 g/cm³ for sample containing 0.5 to 15.0% of TiN in the presence of 4.0 to 25.0% of the total content of MgO and Al₂O₃, and MgO/Al₂O₃ ratio being 2 to 19. Particularly in No. 25, 26, 27, 28 and 29 which have MgO content of from 7.5 to 15.0%, and Al₂O₃ content of from 0.5 to 6% and a TiN content of from 1 to 10% according to the present invention, the strength at 1400°C is excellent, i.e. not less than 500 MPa.

The comparative examples No. 31 to 35, which are not covered within the limited composition area of the present invention, are also shown in Table II for comparison. In the case of No. 36 its density and strength are insufficient, because firing temperature was lower than the present invention. In the case of No. 37 firing temperature was too high, and so its density and strength are insufficient, because of Si_3N_4 volatilization.

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								Firing					
	Sample		ing ra:	Mixing ratio (wt%)	(%)	MgO+A1203	MgO/Al ₂₀₃	temperature	Density	8-form	Flexural	Strength	(MPa)
	No.	Si3N4	MgO	A1203	Tin	(wt%)	(wt ratio)	(_O _O)	(g/cm ³)	(%)	RT	1200°C	1400°C
	21	93.5	5.7	0.3	0.5	0.9	19.0	1800	3.13	85	650	580	380
	22	78.0	18.8	1.2	2.0	20.0	15.7	1800	3.15	87	700	009	400
Present	23	65.0	23.1	1.9	10.0	25.0	12.2	1650	3.11	75	009	490	380
invention	24	86.0	3.3	0.7	10.0	4.0	4.7	1800	3.13	85	640	580	400
	25	87.0	7.5	0.5	5.0	8.0	15.0	1775	3.18	81	730	670	520
	26	83.6	13.7	1.7	1.0	15.4	8.1	1830	3.13	95	740	089	580
	27	74.3	14.7	0.9	5.0	20.7	2.5	1775	3.28	06	740	089	550
	28	82.0	8.8	4.2	5.0	13.0	2.1	1830	3.26	95	720	099	530
	29	72.0	15.0	3.0	10.0	18.0	5.0	1750	3.18	87	700	620	200
	30	62.0	15.3	7.7	15.0	23.0	2.0	1775	3.24	92	650	580	350
			\dagger		+								
	31	92.0	7.0	1.0	!	8.0	7.0	1750	3.13	70	550	440	330
Comparative	32	96.1	2.8	0.1	1.0	2.9	28.0	1800	2.97	85	410	300	280
example	33	0.09	28.6	1.4	10.0	30.0	20.4	1775	3.02	93	450	310	280
	34	61.0	14.7	7.3 1	17.0	22.0	2.0	1775	3.06	95	450	380	250
	35	79.0	12.0	8.0	1.0	20.0	1.5	1775	3.13	95	440	360	200
	36	89.0	5.3	0.7	5.0	0.9	7.6	1600	2.68	65	240	210	200
	37	83.0	9.6	2.4	5.0	12.0	4.0	1850	3.00	100	400	320	210

ABLE II

Example 3

The procedure outlined in detail at Example 1 was repeated but using WC instead of SiC.

In this example, the weight amount of WC in the $\rm Si_3N_4$ was varied from 0 to 17%, the total content of MgO and $\rm Al_2O_3$ was varied from 2.6 to 28%, and the MgO/Al $_2O_3$ ratio was varied from 1.5 to 25.

The various operating parameters and the results are gathered in Table III. The silicon nitride sintered bodies according to the present invention are samples No. 41 to 50 in Table III, while No. 51 to 57 are given as comparative samples. As seen from the results of Table III, the four point flexural strength at 1400°C in air is not less than 370 MPa and density is not less than 3.12 g/cm³ for the sample containing 0.5 to 15.0% of WC in the presence of 4.5 to 25% of the total contents of MgO and Al₂O₃, and with a MgO/Al₂O₃ ratio of 2 to 19. Particularly in No. 45, 46, 47, 48 and 49 which have a MgO content varying from 5 to 15%, an Al₂O₃ content of from 0.8 to 6% and a WC content of from 1 to 10% according to the present invention, the strength at 1400°C is excellent and not less than 450 MPa.

The comparative examples No. 51 to 55 which do not refer to the composition area of the present invention are shown in Table III for reference purpose. In case of No. 56 for instance, the density and strength are insufficient, because the firing temperature was below that of the present invention. In case of No. 57, the firing temperature was too high and consequently the density and strength are insufficient because of Si₃N₄ volatilization.

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	Sample	Mixi	ng ra	Mixing ratio (wt%)	+8)	MGO+ B 1 OO	M~\\ \\ \\ \\ \\ \\ \\ \\ \\ \\ \\ \\ \\	Firing		,			
	4) -	1301 A 1203	MgO/A1203	remperature	Density P-form	P-form	Flexural	Strength	(MPa)
	No.	$\operatorname{Si}_3\mathrm{N4}$	Mgo	A1203	WC	(wt&)	(wt ratio)	(၁ _၀)	(g/cm ³)	(%)	RT	1200°C	1400°c
	. 41	94.5	4.7	0.3	0.5	5.0	15.7	1800	3.12	92	009	550	390
	42	80.0	17.1	6.0	2.0	18.0	19.0	1775	3.16	06	570	520	380
Present	43	65.0	23.5	1.5	10.0	25.0	15.7	1650	3,35	70	550	500	380
invention	44	85.5	4.0	0.5	10.0	4.5	8.0	1830	3,36	93	580	550	380
	45	89.2	5.0	0.8	5.0	5.8	6.3	1750	3.25	83	089	650	200
	46	85.0	12.5	1.5	1.0	14.0	8.3	1775	3.14	97	730	670	540
	47	79.9	12.1	3.0	5.0	15.1	4.0	1775	3.26	93	710	620	530
	48	86.0	6.1	2.9	5.0	0.6	2.1	1800	3.33	97	700	620	520
	49	0.69	15.0	0.9	10.0	21.0	2.5	1750	3.41	93	650	009	450
	50	64.0	14.0	7.0	15.0	21.0	2.0	1800	3.43	95	580	200	370
	51	92.0	7.0	1.0	ŀ	8.0	7.0	1750	3.13	70	550	440	330
Comparative	52	96.4	2.5	0.1	1.0	2.6	25.0	1800	3.04	87	410	320	270
example	53	62.0	26.4	1.6	10.0	28.0	16.5	1775	3,35	94	460	330	250
	54	62.0	14.0	7.0	17.0	21.0	2.0	1775	3.50	96	440	350	230
	55	83.0	9.6	6.4	1.0	16.0	1.5	1750	3.24	83	440	340	200
	56	88.0	6.0	1.0	5.0	7.0	0.9	1600	2.88	29	270	230	200
	57	85.0	8.0	2.0	5.0	10.0	4.0	1850	3.17	100	400	330	250
						•	•	-	-	-	-	-	

Example 4

The procedure outlined in detail at Example 1 was repeated but using TiC or TiB, instead of SiC.

In this example, the weight amount of TiC or ${\rm TiB}_2$ in the ${\rm Si}_3{\rm N}_4$ was 1 or 5%, the total content of MgO and ${\rm Al}_2{\rm O}_3$ was 5.7 or 15.5% and MgO/Al₂O₃ ratio was 7 or 9.3.

The various operating parameters and the results are gathered in Table IV. The silicon nitride sintered bodies of the present in10 vention are No. 61 to 64 in Table IV, while No. 65 is given for comparison. As seen from the results of Table IV, the four point flexural strength at 1400°C in air is not less than 400 MPa and the density is not less than 3.12 g/cm³ for the samples containing 1.0 or
5.0% of TiC or TiB2 in the presence of 5.7 or 15.5% of the total con-

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12000Cl 14000C MgO+Al $_2$ O $_3$ MgO/Al $_2$ O $_3$ temperature Density $m{eta}$ -form Flexural strength (MPa) 450 480 400 420 580 560 620 590 610 꿆 930 550 (%) 80 97 88 85 20 (g/cm^3) 3.12 3.13 3.24 1750 1800 1750 1800 (ဥ 1750 (wt ratio) 9.3 7.0 (wt8) 5.7 15.5 5.7 15.5 8.0 St3N4 MGO | Al2O3 | TiC | TiB2 1.0 Mixing ratio (wt8) 5.0 1.0 14.0 5.0 14.0 7.0 83.5 89.3 83.5 89.3 92.0 Sample Ş Ş 62 63 64 65 Comparative invention Present example

TABLE IV

CLAIMS

- 1. Silicon nitride sintered bodies which contain metal compounds selected from SiC, TiN, WC, TiC and ${\rm TiB}_2$, and ${\rm MgO/Al}_2{\rm O}_3$, characterized in having such metal compounds in a quantity by weight not exceeding 15%, the total amounts of MgO and ${\rm Al}_2{\rm O}_3$ in a quantity by
- 5 weight of 4 to 25% relative to the total of the composition and in having the MgO/Al $_2\mathrm{O}_3$ weight ratio from 19 to 2.
- 2. Silicon nitride sintered bodies according to claim 1, wherein the amount of metal compound selected from SiC, TiN and WC is 1 to 10% by weight, the amount of MgO is 5 to 15% by weight and the amount of Al_2O_3 is 0.5 to 6% by weight.
 - 3. Silicon nitride sintered bodies according to claims 1 or 2, characterized in that their density exceeds 3.10 g/cm³ and their flexural strength at 1400°C is not less than 350 MPa.
- 4. A method of manufacturing silicon nitride sintered bodies by the pressureless sintering of a composition in powder form, which comprises mixing a raw material powder of silicon nitride containing magnesium oxide and aluminium oxide and a metal compound selected from SiC, TiN, WC, TiC and TiB₂, the total amounts of MgO and Al₂O₃ being 4 to 25% by weight of the composition and the MgO/Al₂O₃ weight ratio being from 19 to 2, forming the resulting mixture into an article and firing this article at a temperature of 1650-1830°C in an atmosphere composed essentially of nitrogen.



EUROPEAN SEARCH REPORT

 $0.175041_{\text{.Application number}}$

EP 84 81 0458

Category	Citation of document wit	IDERED TO BE RELEVANT th indication, where appropriate, rant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.4)
A	GB-A-2 035 981 MEMORIAL INSTIT * Claims 1,4 *	(BATTELLE	1,4	C 04 B 35/58
A	GB-A-2 062 688 LTD.) * Claims 1,2,5	 (FORD MOTOR CO.,	1,2	
A	US-A-4 004 937 * Claim 1 *	 (H. MASAKI)	1,4	
A	EP-A-0 079 678 ELECTRIC INDUST: * Claims 7,9; e.	RÌES LTD.)	1,4	
A	EP-A-O 100 380 ELECTRIC INDUST: * Claims 2-5 *		1 -	TECHNICAL FIELDS SEARCHED (Int. Cl.4)
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.	Place of search BERLIN	Date of completion of the search	STROU	Examiner D.G.
Y:pa do	CATEGORY OF CITED DOCI rticularly relevant if taken alone rticularly relevant if combined w cument of the same category chnological background n-written disclosure ermediate document	after the fill vith another D : document L : document	ing date cited in the app cited for other	ying the invention but published on, or olication reasons of tamily, corresponding